Appl. No:
 10/659,992

 Amdt. dated:
 June 7, 2007

 Reply to Office Action of:
 April 5, 2007

Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application: Claims 1-39 have been cancelled. Claims 40-65 are pending.

Listing of Claims:

1. (Cancelled) A method of growing a CdS/ZnS graded shell, comprising:

providing a core,

combining the core with at least one surfactant,

heating the mixture,

combining the mixture with a CdS/ZnS stock solution,

wherein the core comprises a semiconductor material, and

graded core/shell nanorods are produced.

2. (Cancelled) The method of claim 1, wherein:

the core is rod shaped.

3. (Cancelled) The method of claim 2, wherein:

the core comprises CdSe.

4. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 1, wherein:

the mixture is heated to a temperature between 100-360 °C.

5. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 1, wherein:

the mixture is heated to a temperature of 160°C.

6. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 1, wherein:

the core is combined with only one surfactant.

7. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 1, wherein:

the surfactant is chosen from the group consisting of TOPO, TBP, HDA, HPA and

TDPA.

8. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 1, wherein:

the mixture is kept at a temperature of approximately 160° for between 5 minutes and 24 hours after combining the CdS/ZnS stock solution.

- (Cancelled) The method of growing a CdS/ZnS graded shell of claim 8, wherein: the mixture is kept at a temperature of 160°C for 10 minutes after combining the CdS/ZnS stock solution.
- 10. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 1, wherein: the core is a shaped nanorod.
- 11. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 10, wherein: the core has a tetrapod shape.
- 12. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 1, wherein: the graded core/shell nanorods are photochemically annealed.
- (Cancelled) The method of growing a CdS/ZnS graded shell of claim 12, wherein: the annealing is done using an Ar+ laser.
- 14. (Cancelled) A method of growing a CdS/ZnS graded shell, comprising: providing a core/surfactant mixture, heating the mixture,

combining the mixture with a CdS/ZnS stock solution.

- 15. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 14, wherein: the core is rod shaped.
- (Cancelled) The method of growing a CdS/ZnS graded shell of claim 15, wherein: the core comprises CdSe.
- 17. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 14, wherein: the mixture is heated to a temperature between 100-360 °C.
- 18. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 14, wherein:

the mixture is heated to a temperature of 160°C.

 (Cancelled) The method of growing a CdS/ZnS graded shell of claim 14, wherein: the core/surfactant mixture contains only one surfactant.

- 20. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 14, wherein: the surfactant is chosen from the group consisting of TOPO, TBP, HDA, HPA and TDPA.
- 21. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 14, wherein: the mixture is kept at a temperature of approximately 160° for between 5 minutes and 24 hours after combining the CdS/ZnS stock solution.
- 22. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 21, wherein: the mixture is kept at a temperature of 160°C for 10 minutes after combining the CdS/ZnS stock solution.
- 23. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 14, wherein: the core is a shaped nanorod.
- 24. (Cancelled) The method of growing a CdS/ZnS graded shell of claim 23, wherein: the core has a tetrapod shape.
- 25. (Cancelled) A method of growing a graded core/shell semiconductor nanorod, comprising:

providing a semiconductor nanorod core,

combining the core with at least one surfactant,

heating the surfactant/core mixture,

combining the mixture with a solution,

wherein said solution comprises semiconductor precursors in molar ratio sufficient to cause the growth of a graded semiconductor shell on the core.

26. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

25. wherein:

the semiconductor nanorod core comprises a semiconductor material selected from the group consisting of Group II-VI. Group III-V and Group IV semiconductors.

27. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

25, wherein:

the core is rod shaped.

28. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

25, wherein:

the core comprises CdSe.

29. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

25, wherein:

the mixture is heated to a temperature between 100-360 °C.

30. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

29, wherein:

the mixture is heated to a temperature of 160°C.

31. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

25, wherein:

only one surfactant is combined with the core.

32. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

25, wherein:

the surfactant is chosen from the group consisting of TOPO, TBP, HDA, HPA and

TDPA.

33. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

25. wherein:

the mixture is kept at a temperature of approximately 160° for between 5 minutes and 24 hours after combining the solution.

34. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

33, wherein:

the mixture is kept at a temperature of 160°C for 10 minutes after combining the solution.

35. (Cancelled) The method of growing a graded core/shell semiconductor nanorod 25.

wherein:

the core is a shaped nanorod.

36. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

35, wherein:

the core has a tetrapod shape.

37. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

25, wherein:

the graded core/shell nanorod is photochemically annealed.

38. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

37. wherein:

the annealing is done using an Ar+ laser.

39. (Cancelled) The method of growing a graded core/shell semiconductor nanorod of claim

25, wherein:

the core comprises CdSe and the graded shell comprises CdS/ZnS.

40. (Original) A graded core/shell semiconductor nanorod comprising:

at least a first segment comprising:

a core comprising a Group II-VI, Group III-V or a Group IV semiconductor,

a graded shell overlying the core,

wherein the graded shell comprises at least two monolayers,

wherein the at least two monolayers each independently comprise a Group II-VI, Group III-V or a Group IV semiconductor.

41. (Original) The graded core/shell semiconductor nanorod of claim 40, wherein:

the graded shell has at least three monolayers, and

the monolayer closest to the core comprises a first semiconductor material, and the outermost monolayer comprises a second semiconductor material, wherein between the monolayer closest to the core and the outermost monolayer there exists a concentration gradient of the first and second semiconductor material.

- (Original) The graded core/shell semiconductor nanorod of claim 40, wherein: the number of monolayers is between two and eight.
- 43. (Original) The graded core/shell semiconductor nanorod of claim 42, wherein: the number of monolayer is between 2 and 6.
- 44. (Original) The graded core/shell semiconductor nanorod of claim 40, wherein: there is a tail extending longitudinally from the core.
- 45. (Original) The graded core/shell semiconductor nanorod of claim 40, wherein: the core comprises CdSe and the graded core/shell comprises CdS/ZnS.
- 46. (Original) The graded core/shell semiconductor nanorod of claim 40, wherein: there is joined to the first segment a second segment comprising: a core comprising a Group II-VI, Group III-V or a Group IV semiconductor,

a graded shell overlying the core,

wherein the graded shell comprises at least two monolayers.

wherein the at least two monolayers each independently comprise a Group II-VI, Group III-V or a Group IV semiconductor.

- 47. (Original) The graded core/shell semiconductor nanorod of claim 46, wherein: the second segment core comprises CdSe and the second segment graded shell monolayers comprise, in order, CdS/ZnS.
- 48. (Original) The graded core/shell semiconductor nanorod of claim 47, wherein: the first and the second segments have different cross sectional areas.
- 49. (Original) The graded core/shell semiconductor nanorod of claim 47, wherein: there is a third segment joined to the second segment.
- (Original) The graded core/shell semiconductor nanorod of claim 49, wherein: the first, second and third segments have different cross sectional areas.
- 51. (Currently Amended) A nanorod barcode, comprising:

52. (Original) The nanorod barcode of claim 51, wherein:

- a first segment of a first material; and
- a second segment of a second material joined longitudinally to said first segment; wherein at least one of the first and second segments is eapable-of-configured to generate generating-emission in response to excitation energy.
- said first and second segments comprise a nanorod core, and
 said first and second segment cores independently comprise either a semiconductor
 material selected from the group consisting of Group II-VI, Group III-V and Group IV

semiconductors or a metal selected from the group consisting of transition metals, oxides and nitrides thereof.

53. (Original) The nanorod barcode of claim 52, wherein:

said first and second segment cores independently comprise a semiconductor material selected from the group consisting of Group II-VI, Group III-V and Group IV semiconductors

54. (Original) The nanorod barcode of claim 52, wherein:

said first segment core comprises a metal selected from the group consisting of transition metals, oxides and nitrides thereof, and

said second segment comprises a semiconductor material selected from the group consisting of Group II-VI, Group III-V and Group IV semiconductors.

- 55. (Original) The nanorod barcode of claim 52, further comprising:
 - a third segment connected longitudinally to said first segment core, and said third segment core comprising a semiconductor material selected from the group consisting of Group II-VI, Group III-V and Group IV semiconductors.
- 56. (Original) The nanorod barcode of claim 55, wherein: said second and third segments have different cross sectional areas.
- 57. (Original) The nanorod barcode of claim 55, wherein: said first segment core comprises Co, and said second and third segment cores comprise CdSe.
- 58. (Original) The nanorod barcode of claim 53, wherein: said first and second segments have different cross sectional areas.
- 59. (Original) The nanorod barcode of claim 58, wherein: at least one of said first and second segment cores have a graded shell overlying the core.
- 60. (Original) The nanorod barcode of claim 58, wherein: both segment cores have a graded shell overlying said cores.

61. (Original) The nanorod barcode of claim 53, wherein:

there is a third segment joined longitudinally to said second segment, and said third segment comprises a semiconductor material selected from the group consisting of Group II-VI, Group III-V and Group IV semiconductors.

62. (Original) The nanorod barcode of claim 61, wherein: at least one of said first and second and third segment cores have a graded shell overlying the core.

63. (Original) The nanorod barcode of claim 62, wherein: all segment cores have a graded shell overlying the cores.

64. (Original) The nanorod barcode of claim 55, wherein: said first, second and third segments have different cross sectional areas.

65. (Original) A method of using a nanorod barcode to identify an element, comprising: labeling at least one identifiable element with at least one nanorod barcode as claimed in claim 51.